

# Iron Oxide Growth on YSZ(001)

SAND2011-8230C

Ivan Ermanoski and G. L. Kellogg

Sandia National Laboratories

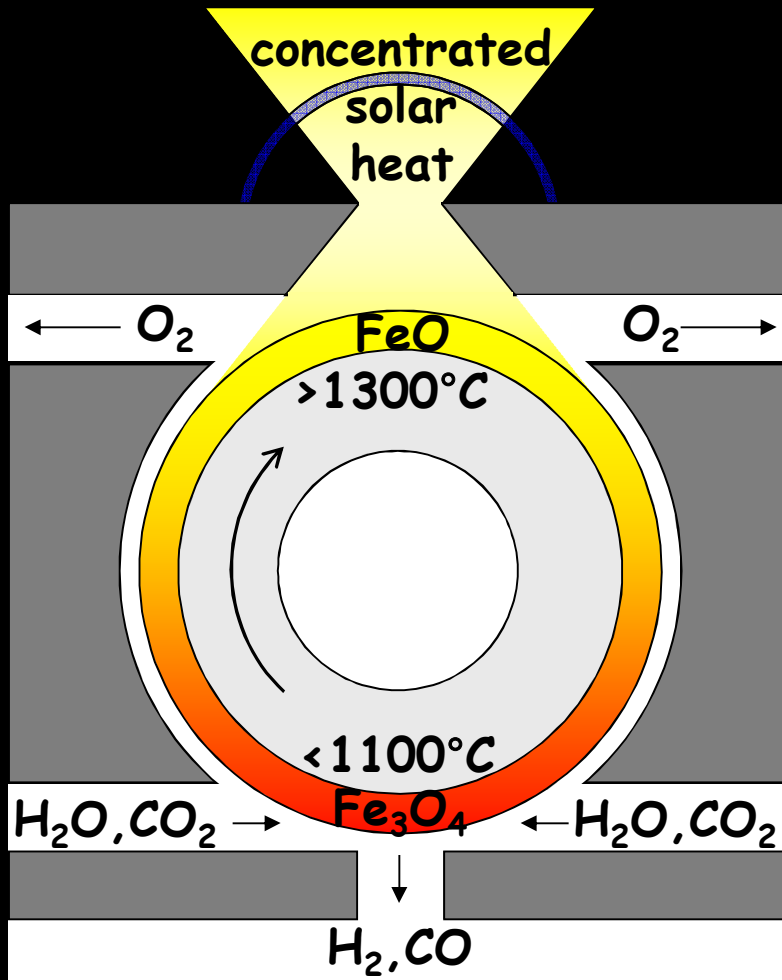
AVS 58<sup>th</sup> International Symposium  
Nashville, TN, Oct.-Nov. 2011

Sandia National Laboratories is a multi program laboratory operated by Sandia Corporation, a wholly owned subsidiary of Lockheed Martin Company, for the U.S. Department of Energy's National Nuclear Security Administration under contract DE AC0494AL85000. Funding for this work was provided through Sandia's LDRD Office.

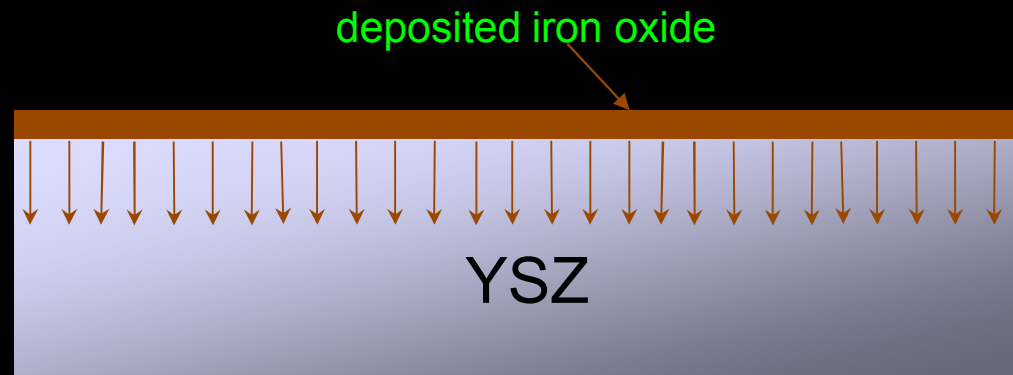
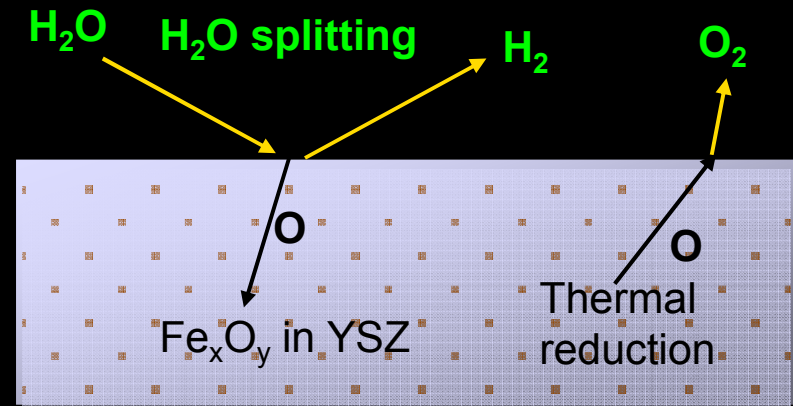


# The Sunshine-to-Petrol Grand Challenge (S2P)

Goal: To produce liquid hydrocarbon fuels from  $\text{CO}_2$  and  $\text{H}_2\text{O}$  using concentrated solar power.

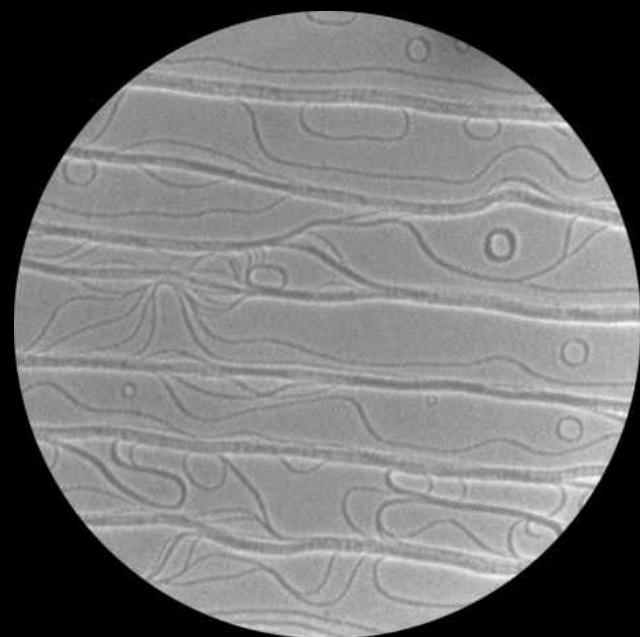


Counter-Rotating-Ring Receiver/Reactor/Recuperator (CR5) increases efficiency by recapturing heat



# Clean YSZ(001): Imaging Above 300°C

YSZ prepared by heating to 1375°C in air  
and subsequent heating in  $5 \times 10^{-7}$  Torr  $O_2$  at 300-350°C

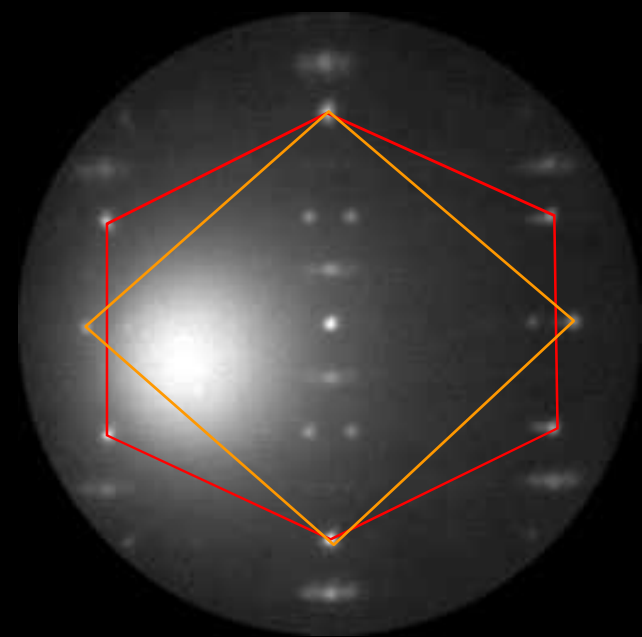


LEEM image

Step bunches: thick horizontal lines  
Single steps: thin meandering lines  
field of view = 20  $\mu\text{m}$



(2x2) LEED pattern at 350°C  
sample is transparent/white

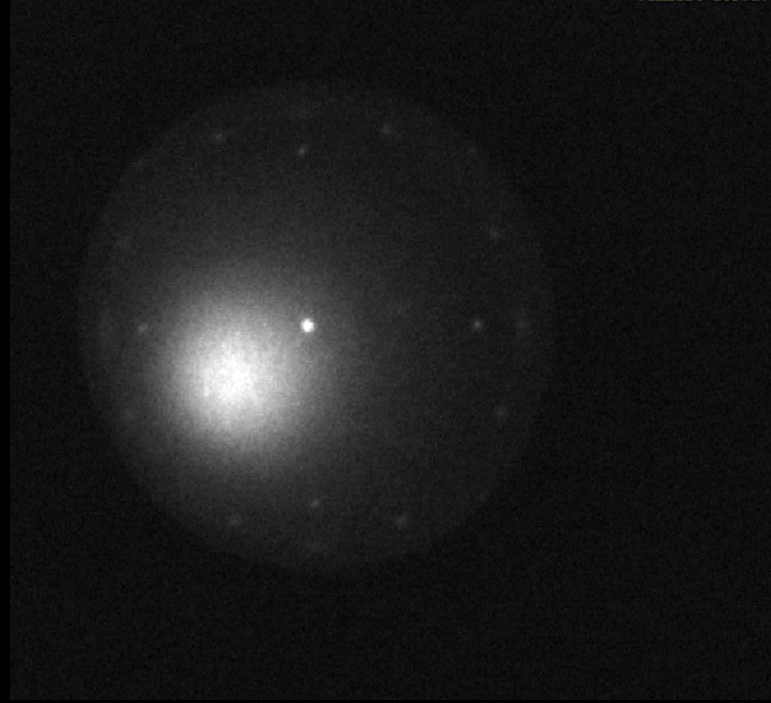


“hex” LEED pattern: above 1200°C  
sample is opaque/black

# “Hex” Substrate: Oxide Growth by Fe Dosing in $\sim 5 \times 10^{-6}$ Torr $O_2$

15:12:51:968  
Sample Temp.=905.0C  
Start Voltage=22.0V

Objective=1406.7mA  
FOV=LEED  
Exp=0.100s,Avr=0,SCy=0  
Wehnelt=259.2V



LEED pattern of Fe deposition on YSZ(001)  
T  $\sim 1000^\circ\text{C}$ ,  $p_{O_2} = 3 \times 10^{-6}$  Torr  
total time  $\sim 30$  min

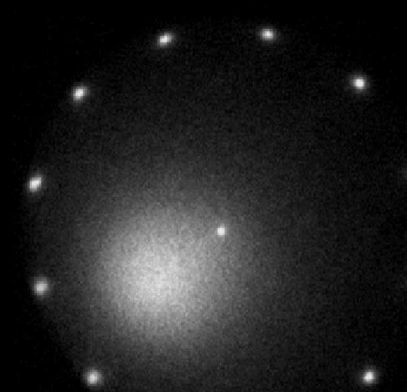
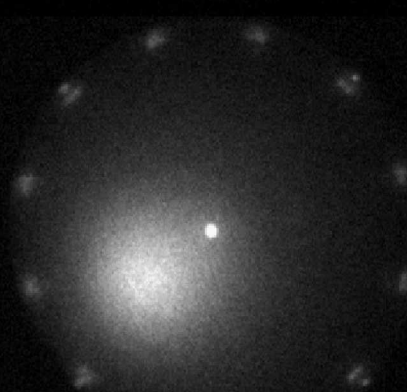
0m 0s

4m 6s



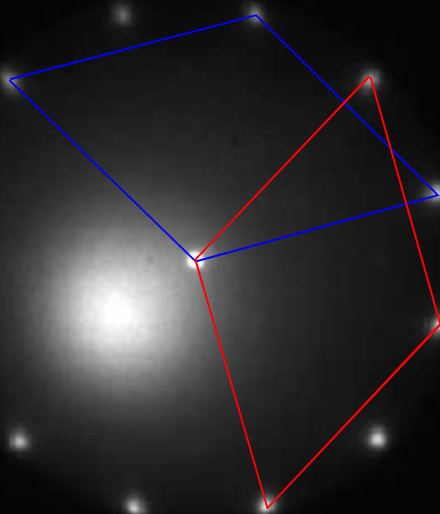
22m 7s

28m 17s

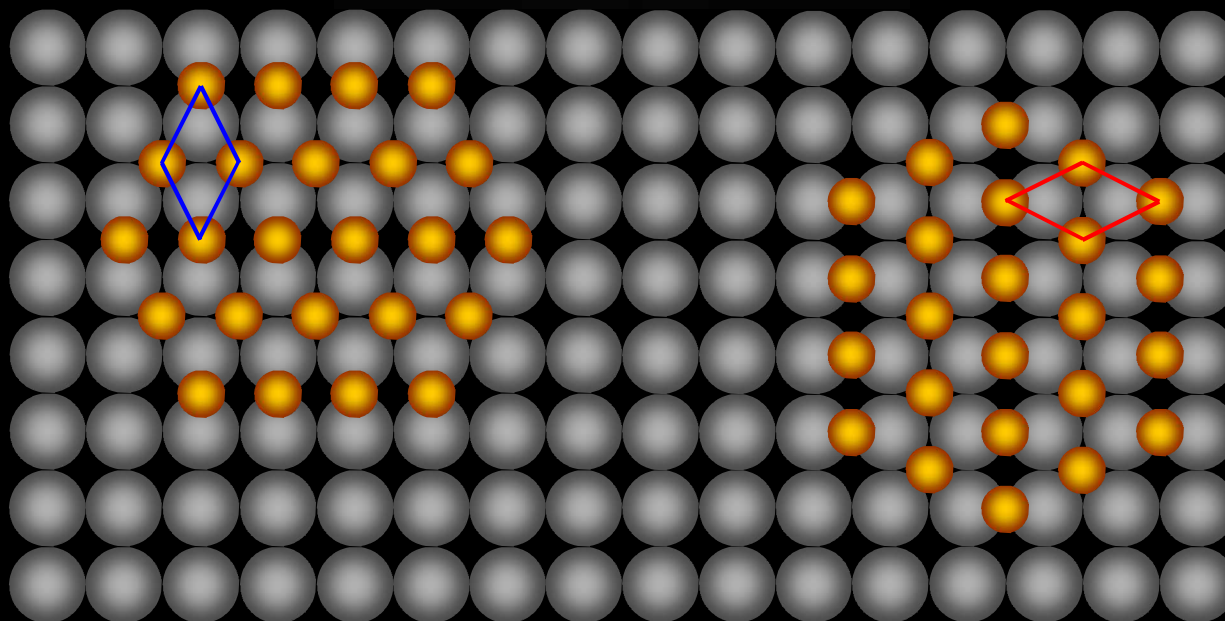


- “Hex” reconstruction disappears after only a few minutes
- A 12-fold pattern appears and converges

# LEED: Two Rotational Domains of FeO

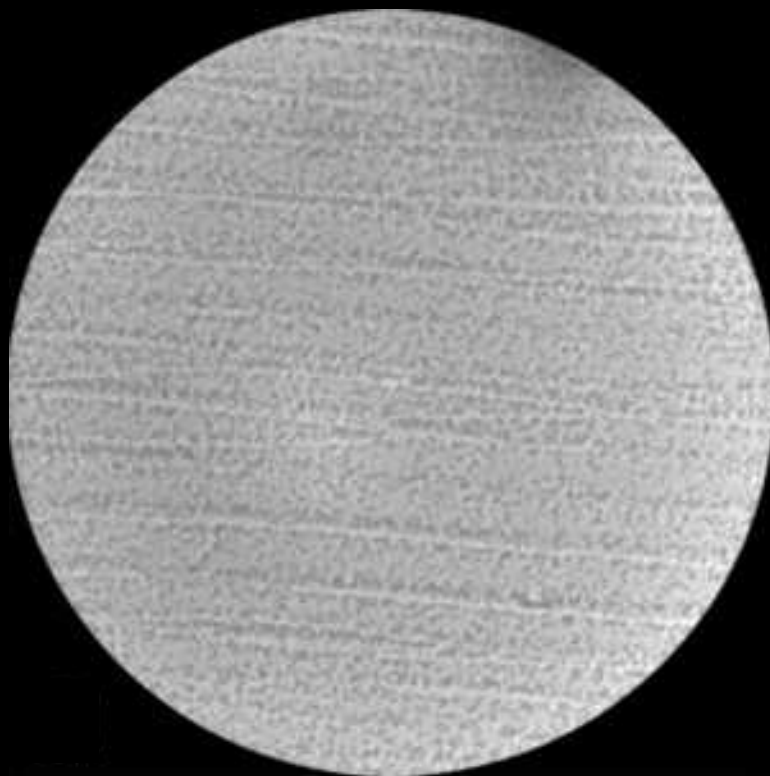


Measured lattice constant: 0.316 nm  
FeO(111) lattice constant: 0.304 nm  
Not Fe<sub>2</sub>O<sub>3</sub>: 0.503 nm  
Not Fe<sub>3</sub>O<sub>4</sub>: 0.592 nm

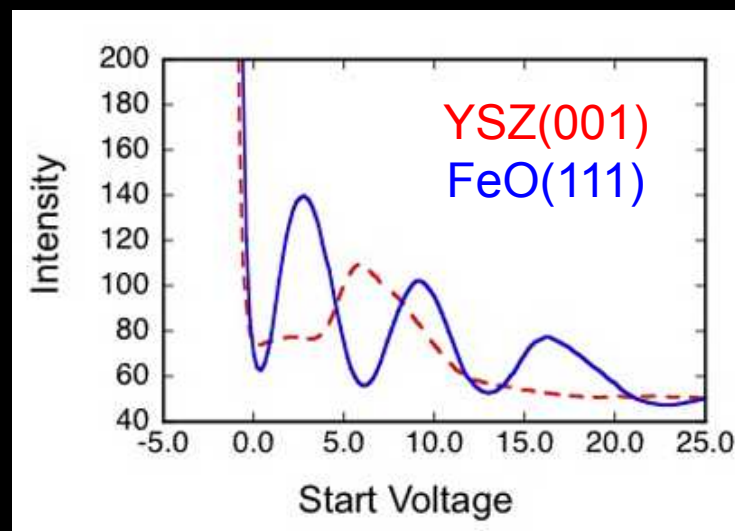


Oxide films grown at ~1000°C are FeO(111) with 2 rotational domains

# LEEM: Non-uniform Growth and IV Surface Fingerprinting



LEEM image of FeO(111)/YSZ(001) film  
deposition  $T \sim 1000^{\circ}\text{C}$   
field of view =  $20 \mu\text{m}$

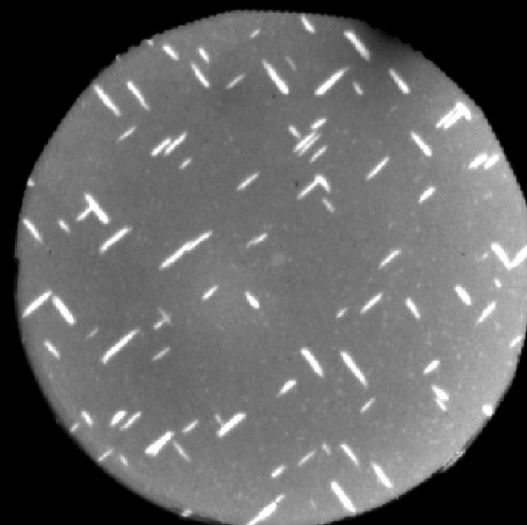
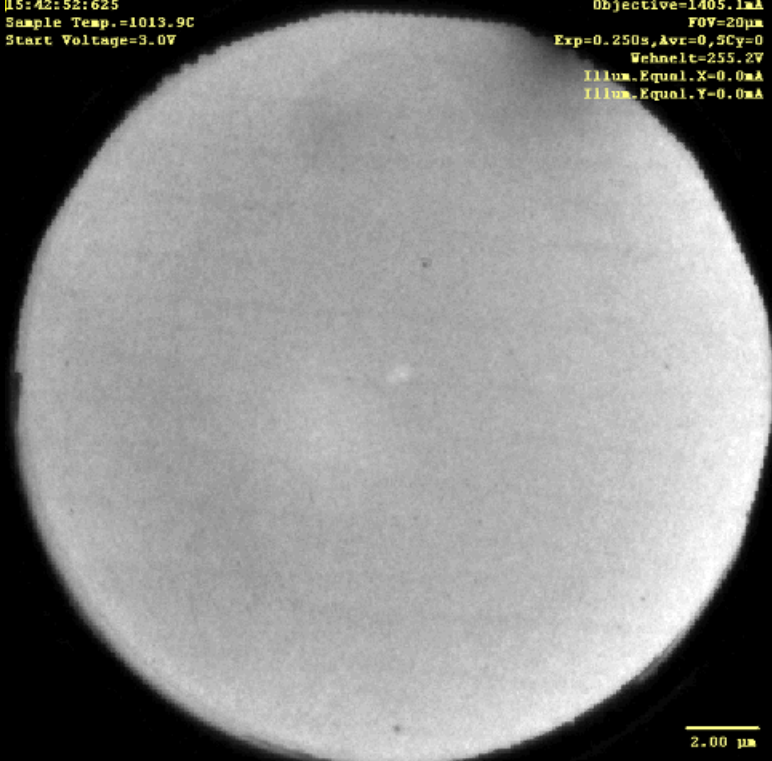


LEEM IV curves for the clean YSZ(001)  
surface and following FeO deposition

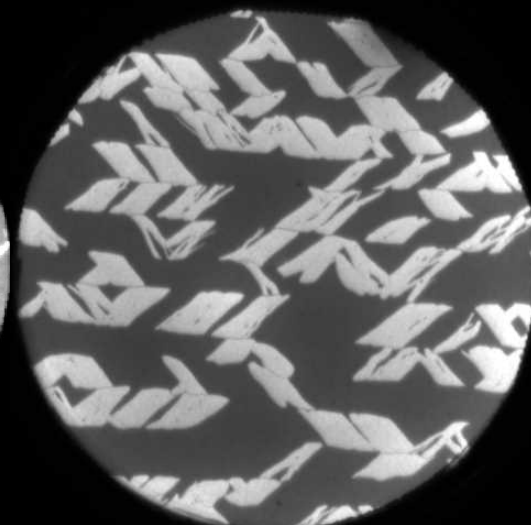
# Higher T: More Uniform FeO Film Growth

[5:42:52:625  
Sample Temp.=1013.9C  
Start Voltage=3.0V

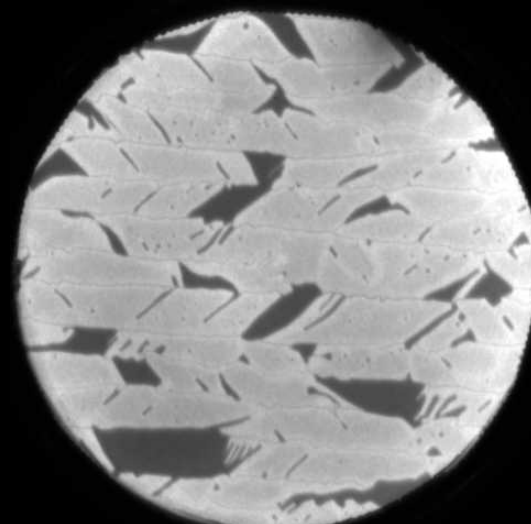
Objective=1405.1mA  
FOV=20µm  
Exp=0.250s,Avr=0.5Cy=0  
Wehnelt=255.2V  
Illum.Equal.X=0.0mA  
Illum.Equal.Y=0.0mA



14m 9s



19m 9s

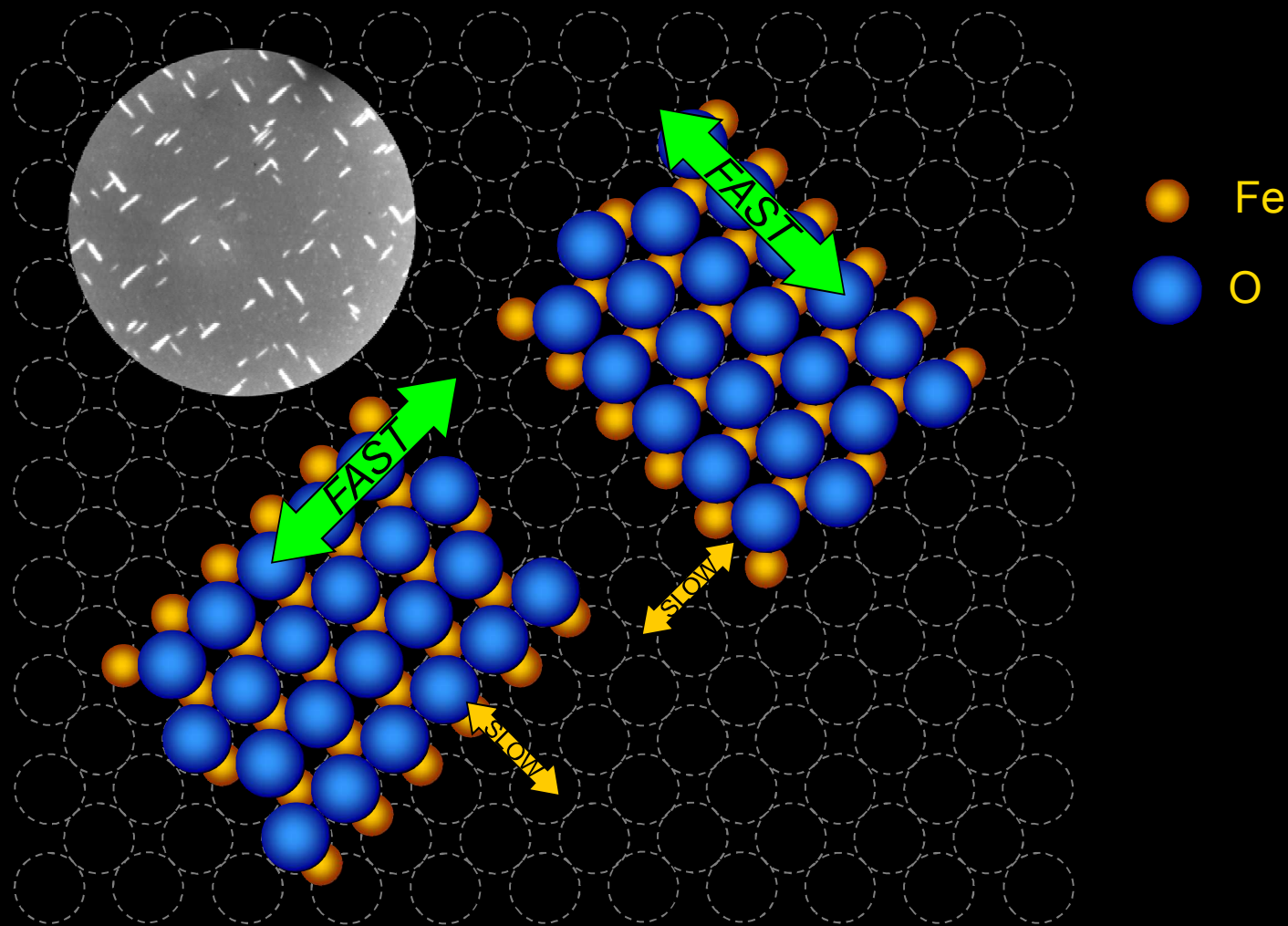


28m 4s

LEEM: Fe/YSZ(001) deposition sequence  
 $T \sim 1110^\circ\text{C}$ ,  $p_{\text{O}_2} = 3 \times 10^{-6}$  Torr  
total time  $\sim 15$  min, FOV=20µm

- No growth at  $1100^\circ\text{C}$
- Must “seed” at  $1000^\circ\text{C}$
- Fast growth in 2 perpendicular directions:
  - Initially high aspect ratio islands
  - Terminates at step bunches
- Slow growth causes island widening

## 2 Rotational Domains – 2 Fast Growth Directions



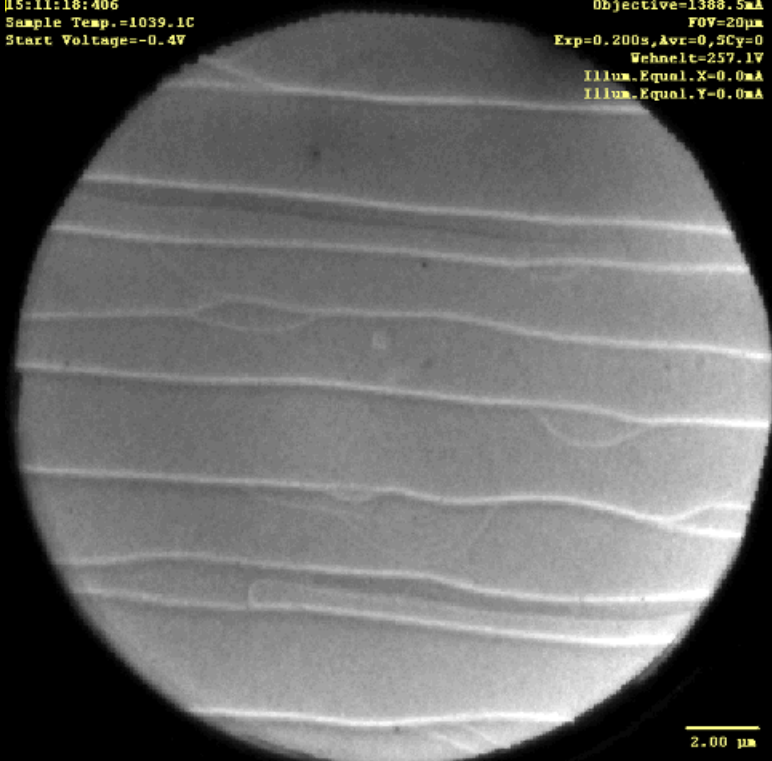
Different atomic configurations at edges leads to different growth speeds

- Preferential attachment
- Anisotropic diffusion
- Preferential oxygen dissociation

# Higher T $\rightarrow$ Larger Domains $\rightarrow$ Probe Domain Structure

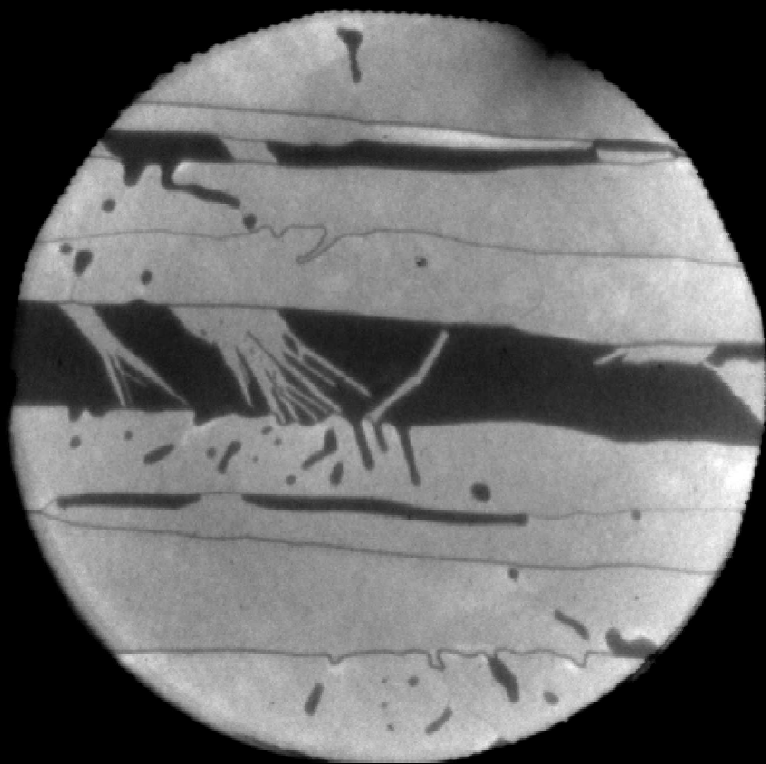
15:11:18:406  
Sample Temp.=1039.1C  
Start Voltage=-0.4V

Objective=1388.5mA  
FOV=20 $\mu$ m  
Exp=0.200s,Avr=0,5Cy=0  
Wehnelt=257.1V  
Illum.Equal.X=0.0mA  
Illum.Equal.Y=0.0mA

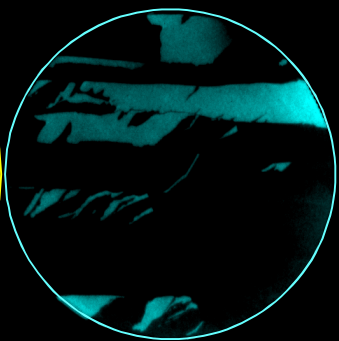
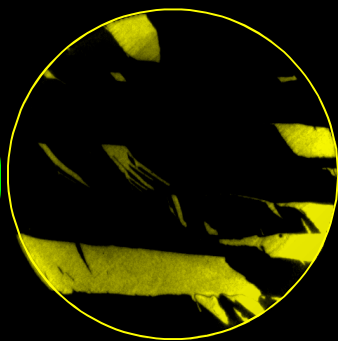
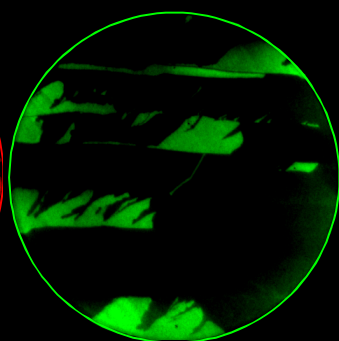
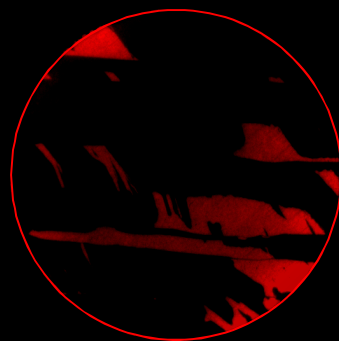
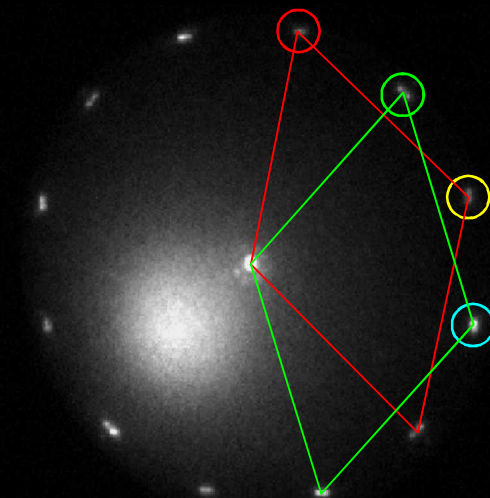


Fe/YSZ(001) deposition sequence  
T~1110°C,  $p_{O_2} = 3 \times 10^{-6}$  Torr  
total time ~23 min, FOV=20 $\mu$ m

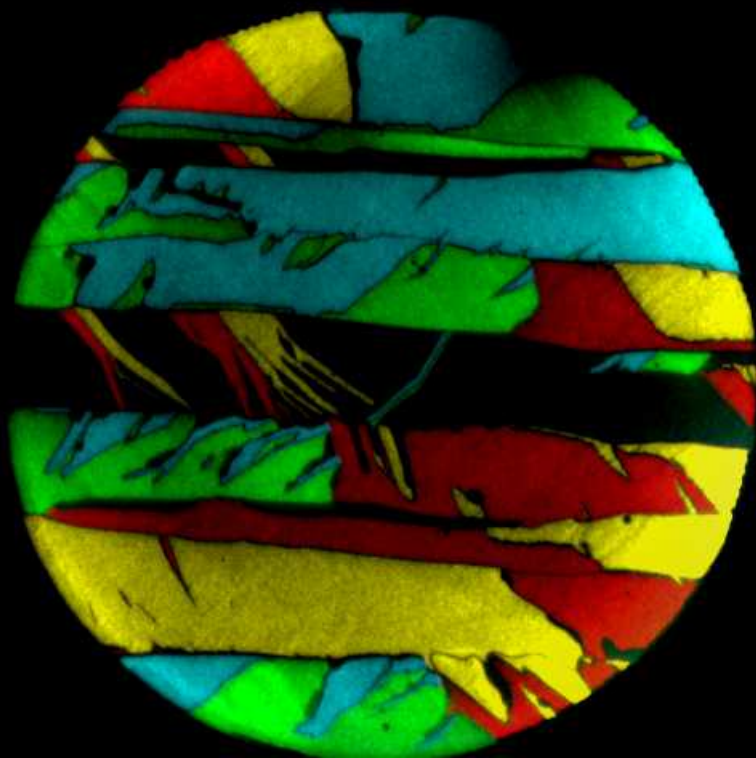
# Higher T $\rightarrow$ Larger Domains $\rightarrow$ Probe Domain Structure



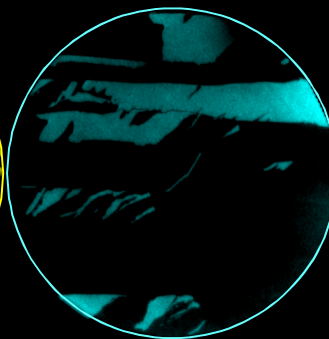
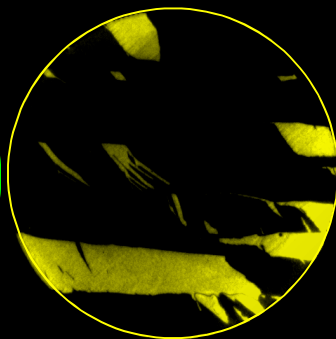
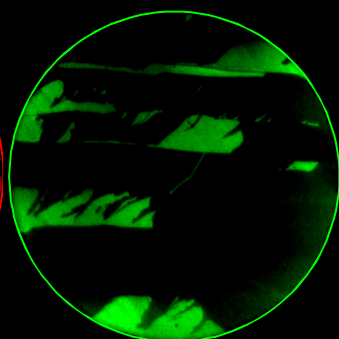
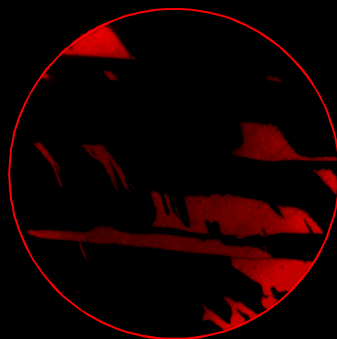
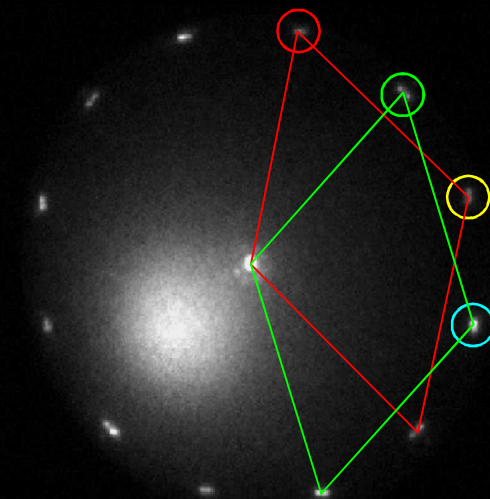
LEEM image of FeO(111)/YSZ(001) film  
FOV=20 $\mu$ m



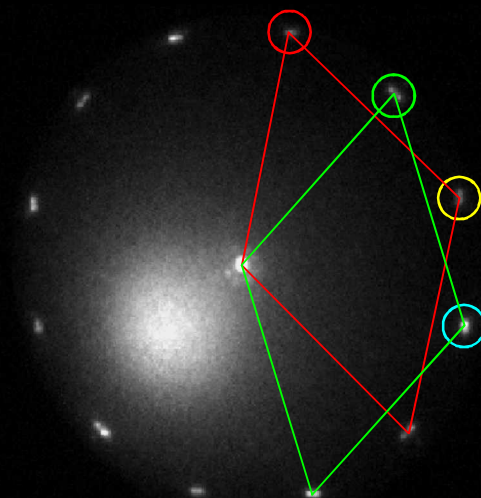
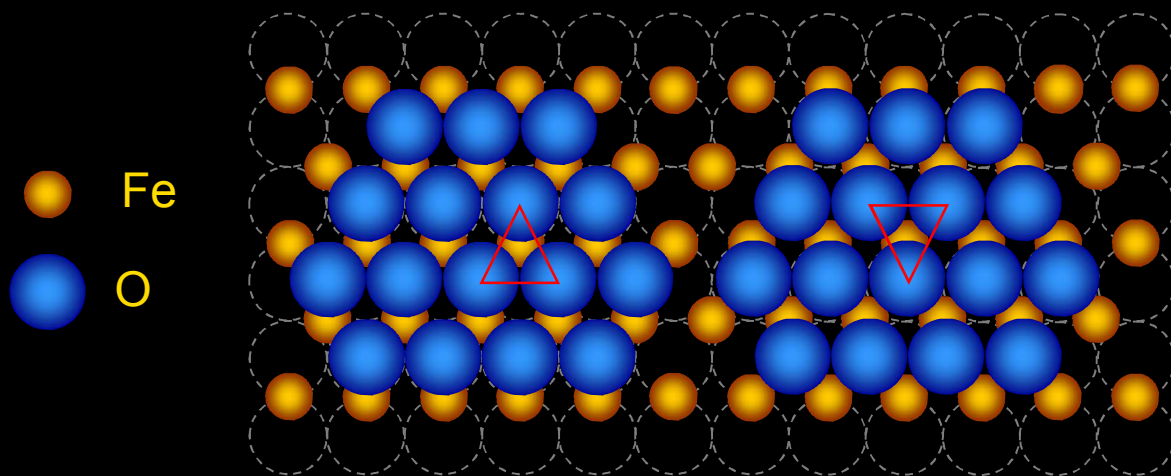
# Dark field LEEM Reveals Double the Domains



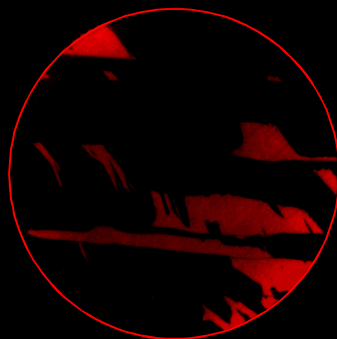
Composite LEEM image of  
FeO(111)/YSZ(001) film domains  
FOV=20 $\mu$ m



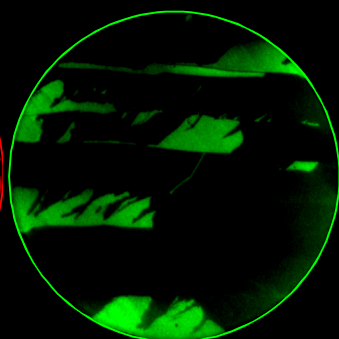
# Origin of 4 Domains: 2 Stackings for Each Rotation



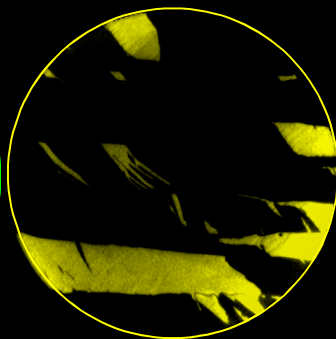
Rotation A  
Stacking X



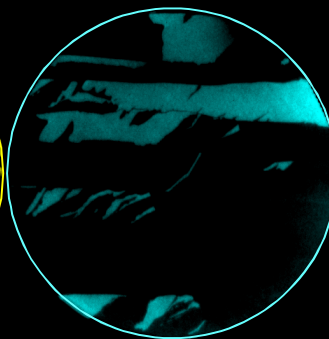
Rotation B  
Stacking X



Rotation A  
Stacking Y



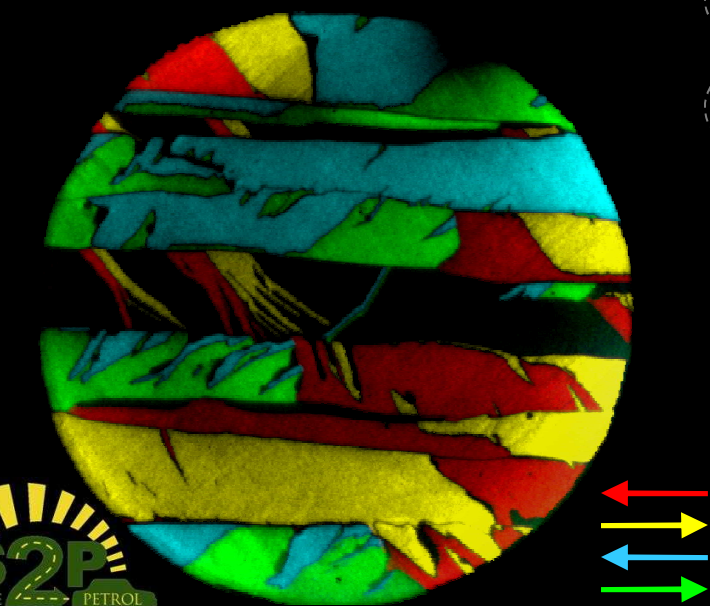
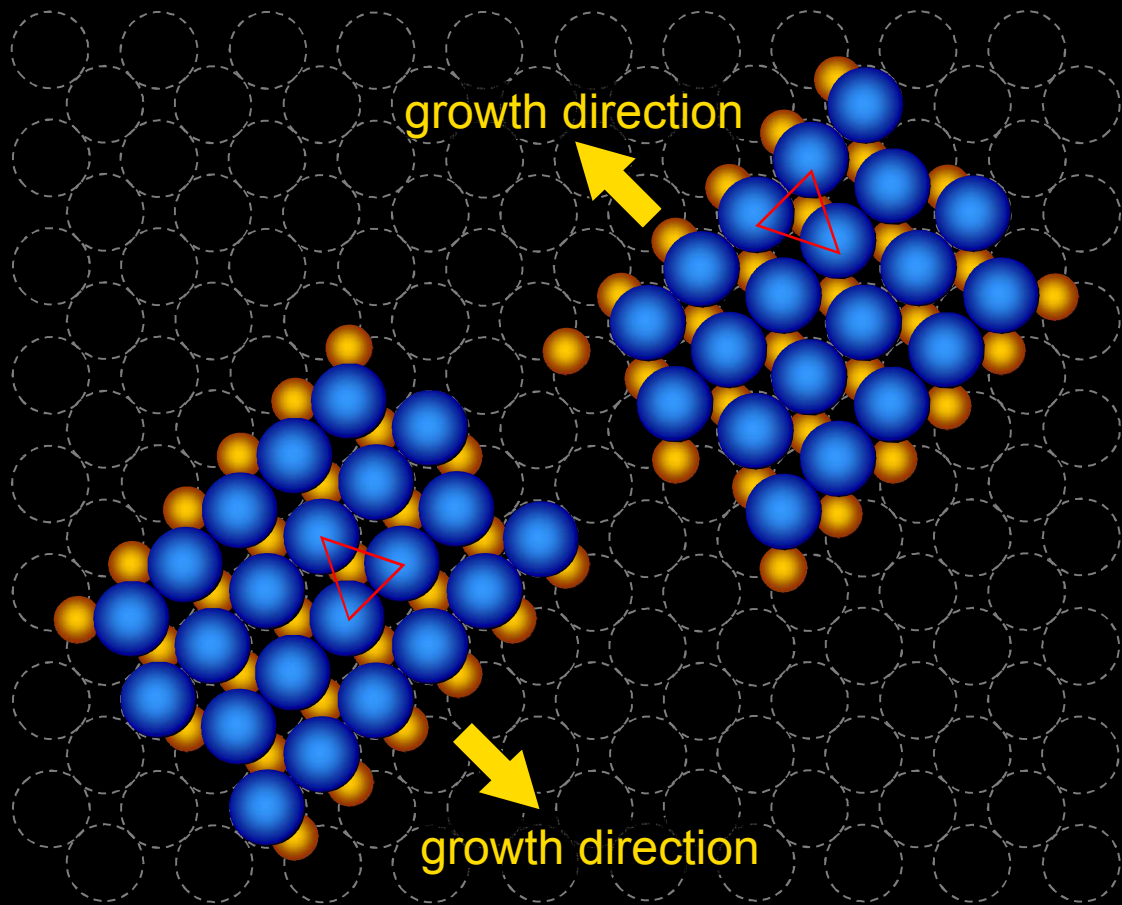
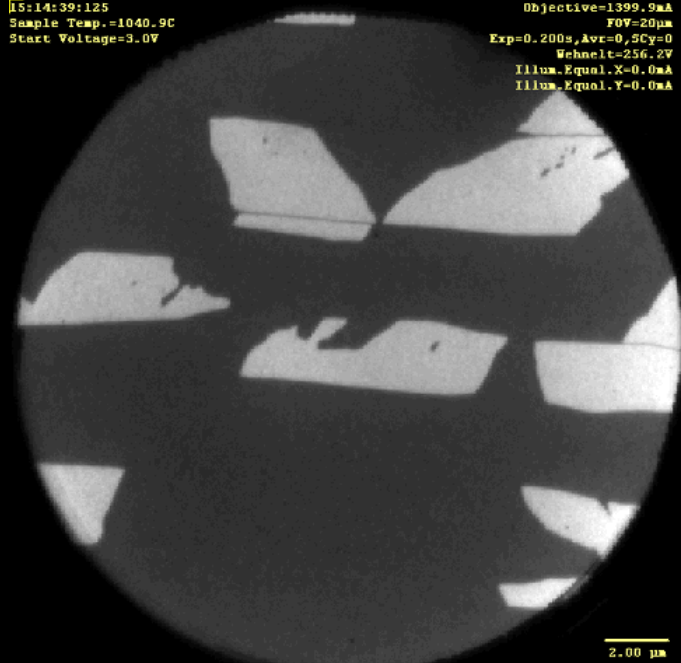
Rotation B  
Stacking Y



# Bilayer Stacking Order Determines Slow Growth Direction

[15-14:39:125  
Sample Temp.=1040.9C  
Start Voltage=3.0V

Objective=1399.9mA  
FOV=20µm  
Exp=0.200s,Avr=0,SCY=0  
Wehnelt=256.2V  
Illum.Equal.X=0.0mA  
Illum.Equal.Y=0.0mA



Probable cause: preferential oxygen dissociation:

- Growth rate increases and is more uniform with increase in oxygen pressure

# FeO(111): High Temperature Morphological Transformation

16:40:03:187

Sample Temp.=894.4C  
Start Voltage=3.0V

Objective=1397.2mA

FOV=20µm

Exp=0.200s,Avr=0,SCY=0

Wehnelt=255.7V

Illum.Equal.X=0.0mA

Illum.Equal.Y=0.0mA

16:40:55:031

Sample Temp.=1160.3C

Start Voltage=3.0V

853474188=1000.56A

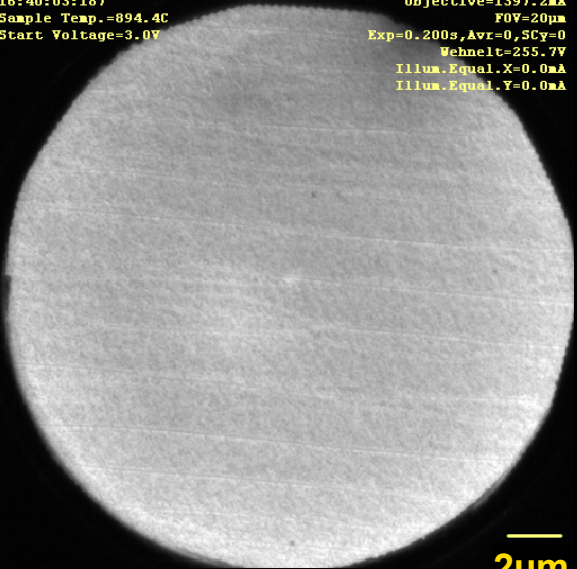
FOV=20µm

Exp=0.200s,Avr=0,SCY=0

Wehnelt=255.7V

Illum.Equal.X=0.0mA

Illum.Equal.Y=0.0mA



990°C



FeO/YSZ(001) annealing sequence  
T~1090-1160°C,  $p_{O_2} = 5 \times 10^{-6}$  Torr  
total time ~8 min, FOV=20µm

# FeO(111): High Temperature Morphological Transformation

16:40:03:187  
Sample Temp.=894.4C  
Start Voltage=3.0V

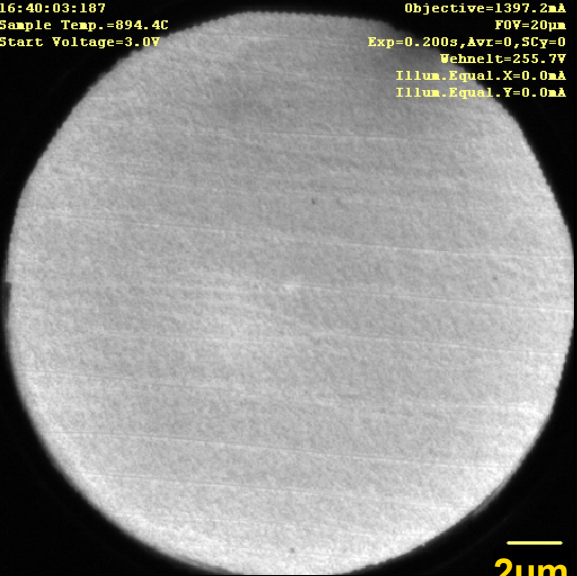
Objective=1397.2mA  
FOV=20µm  
Exp=0.200s,Avr=0,SCY=0  
Wehnelt=255.7V  
Illum.Equal.X=0.0mA  
Illum.Equal.Y=0.0mA

16:48:47:859  
Sample Temp.=1030.7C  
Start Voltage=3.0V

Objective=1401.8mA  
FOV=20µm  
Exp=0.200s,Avr=0,SCY=0  
Wehnelt=255.7V  
Illum.Equal.X=0.0mA  
Illum.Equal.Y=0.0mA

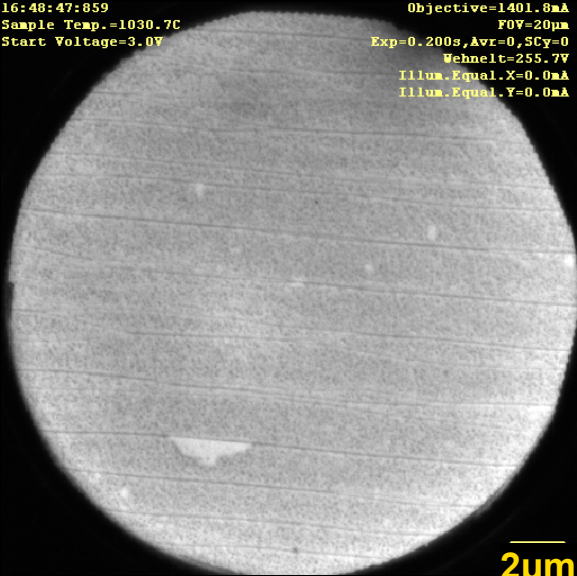
16:54:57:796  
Sample Temp.=1069.0C  
Start Voltage=3.0V

Objective=1403.2mA  
FOV=20µm  
Exp=0.200s,Avr=0,SCY=0  
Wehnelt=255.7V  
Illum.Equal.X=0.0mA  
Illum.Equal.Y=0.0mA



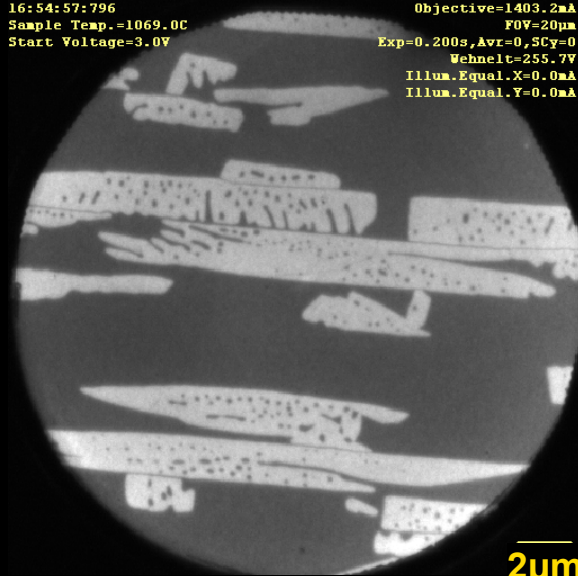
990°C

2µm



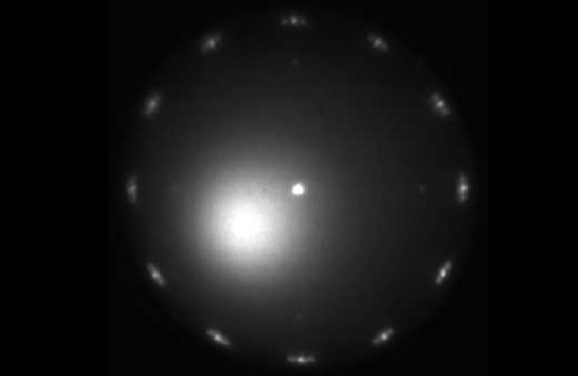
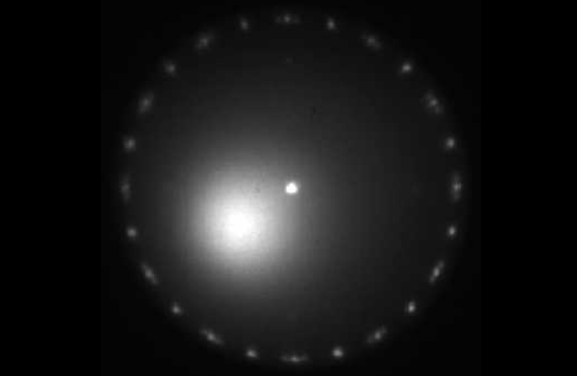
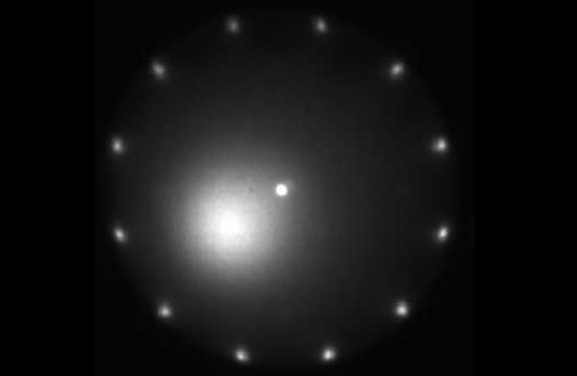
1120°C

2µm



1160°C

2µm

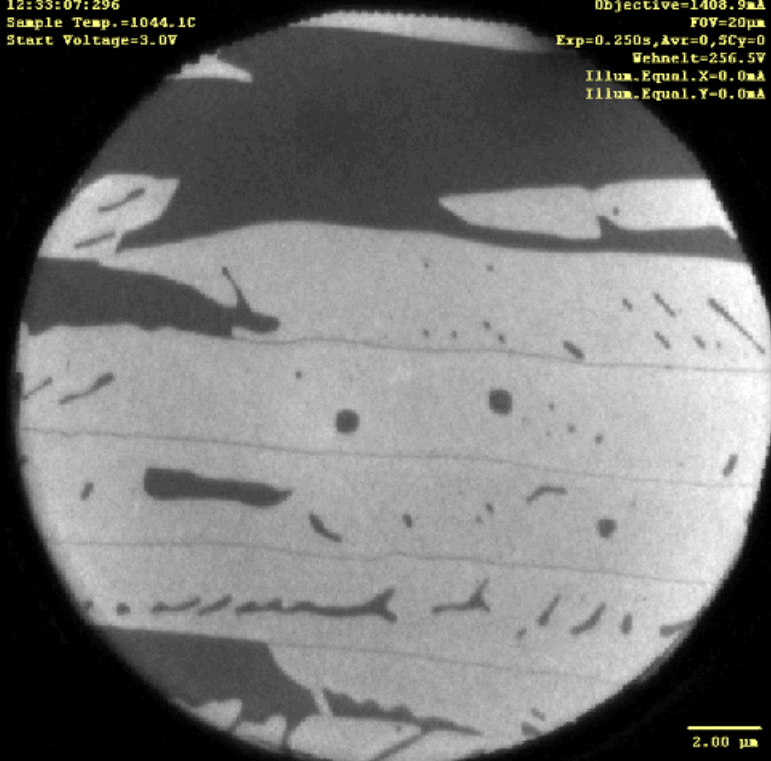


- Lattice is (still) consistent with FeO(111)
- Triplet spots caused by rotated domains
- Rotated structure is stable to higher T
- Double bilayer formation (surface dewetting)?

# Second Layer Growth Only When First Complete

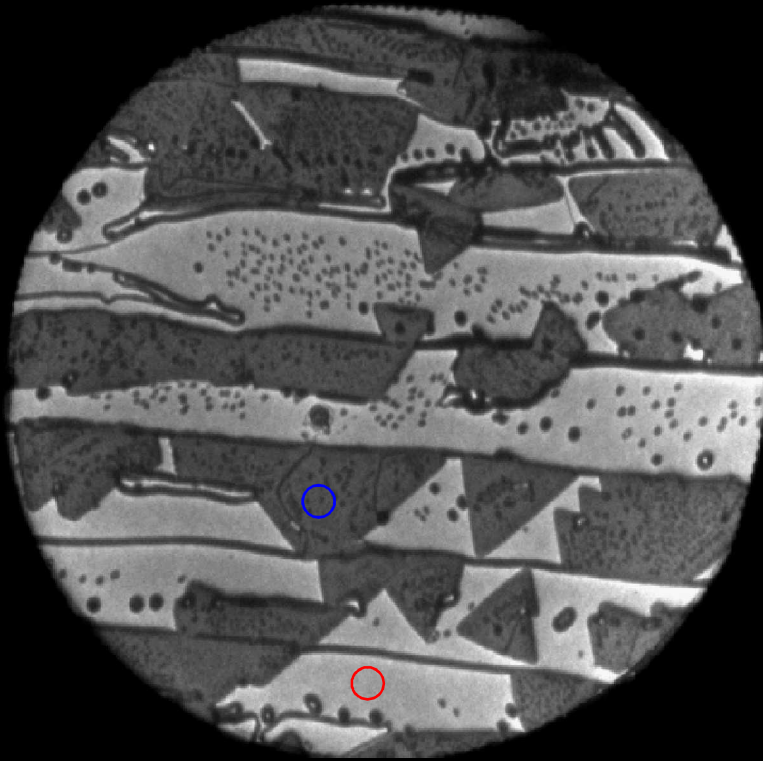
12:33:07:296  
Sample Temp.=1044.1C  
Start Voltage=3.0V

Objective=1408.9mA  
FOV=20µm  
Exp=0.250s,Avr=0,5Cy=0  
Wehnelt=256.5V  
Illum.Equal.X=0.0mA  
Illum.Equal.Y=0.0mA

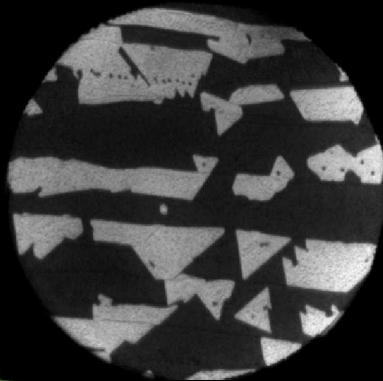


Fe/YSZ(001) deposition sequence  
T~1130°C→1110°C→1000°C,  
 $p_{O_2} = 5 \times 10^{-6}$  Torr  
total time ~180 min, FOV=20µm

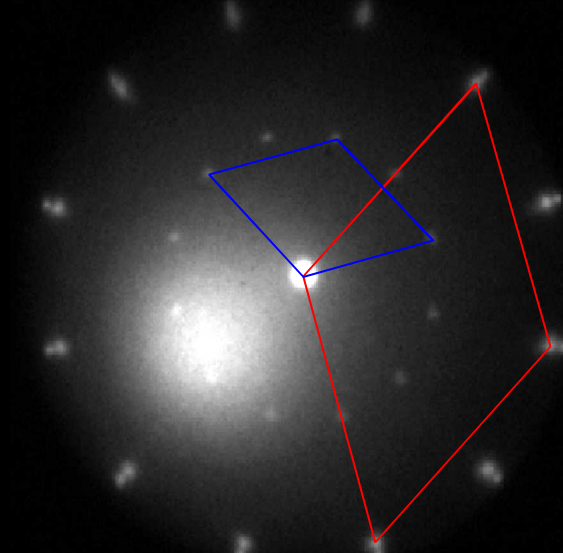
# Second Layer Growth: $\text{Fe}_3\text{O}_4$



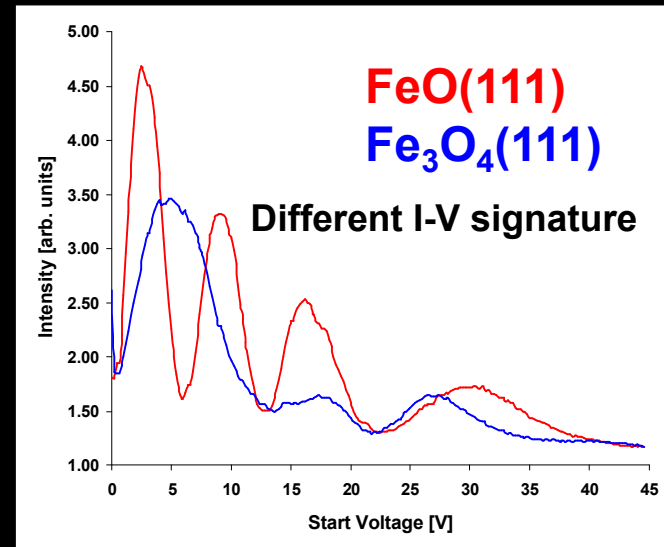
LEEM image of  $\text{FeO}(111)$  and  $\text{Fe}_3\text{O}_4(111)/\text{YSZ}(001)$   
FOV=20 $\mu\text{m}$ , start voltage 2.8V



Same area  
at 5.8V



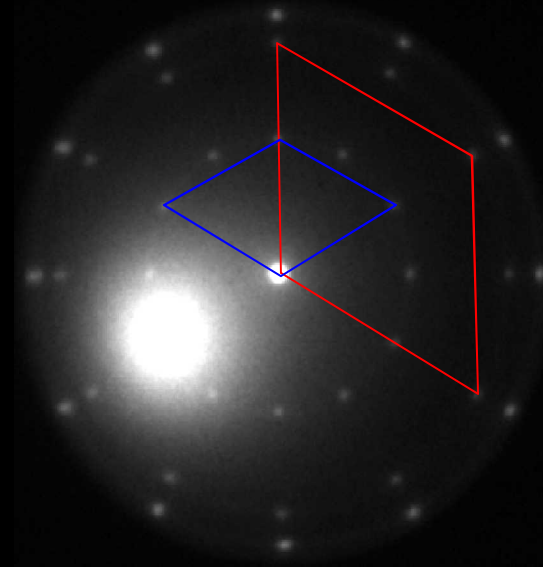
$\text{Fe}_3\text{O}_4(111)/\text{FeO}(111)$  lattice constant ratio: 1.947  
Measured in LEED: 1.92



# Oxide Growth on Fully Oxidized YSZ(001)

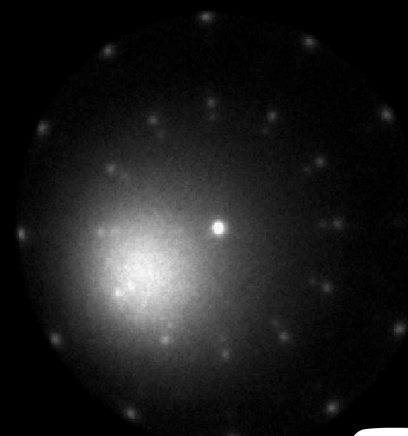


Fe/YSZ(001)  
T~795°C,  $p_{O_2} = 6 \times 10^{-6}$  Torr  
t~42 min

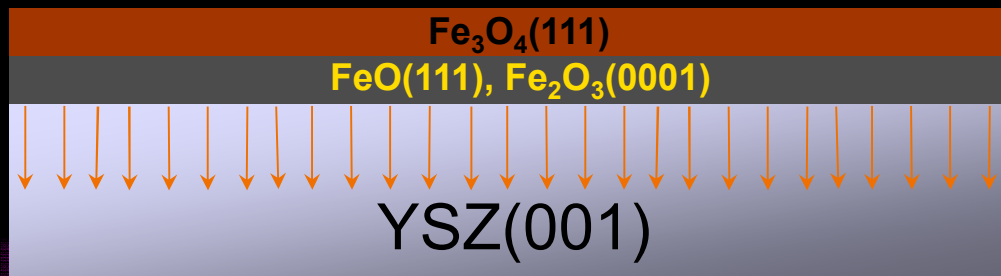


$Fe_2O_3(0001)/FeO(111)$  lattice constant ratio: 1.655  
Measured in LEED: 1.67-1.70

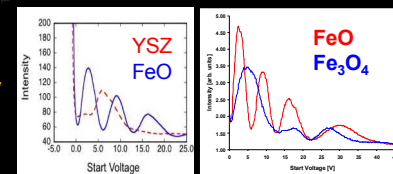
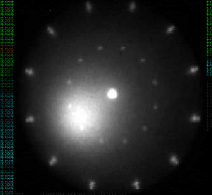
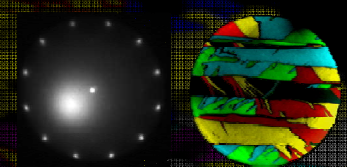
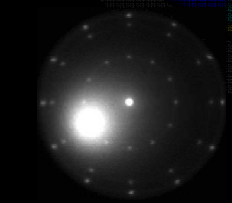
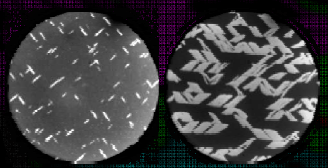
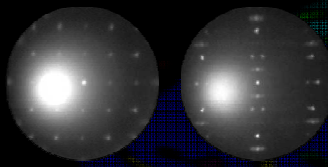
- Simultaneous oxide growth
- Lattice constant consistent with  $Fe_2O_3$
- All 3 oxides can be grown in more elaborate experiments

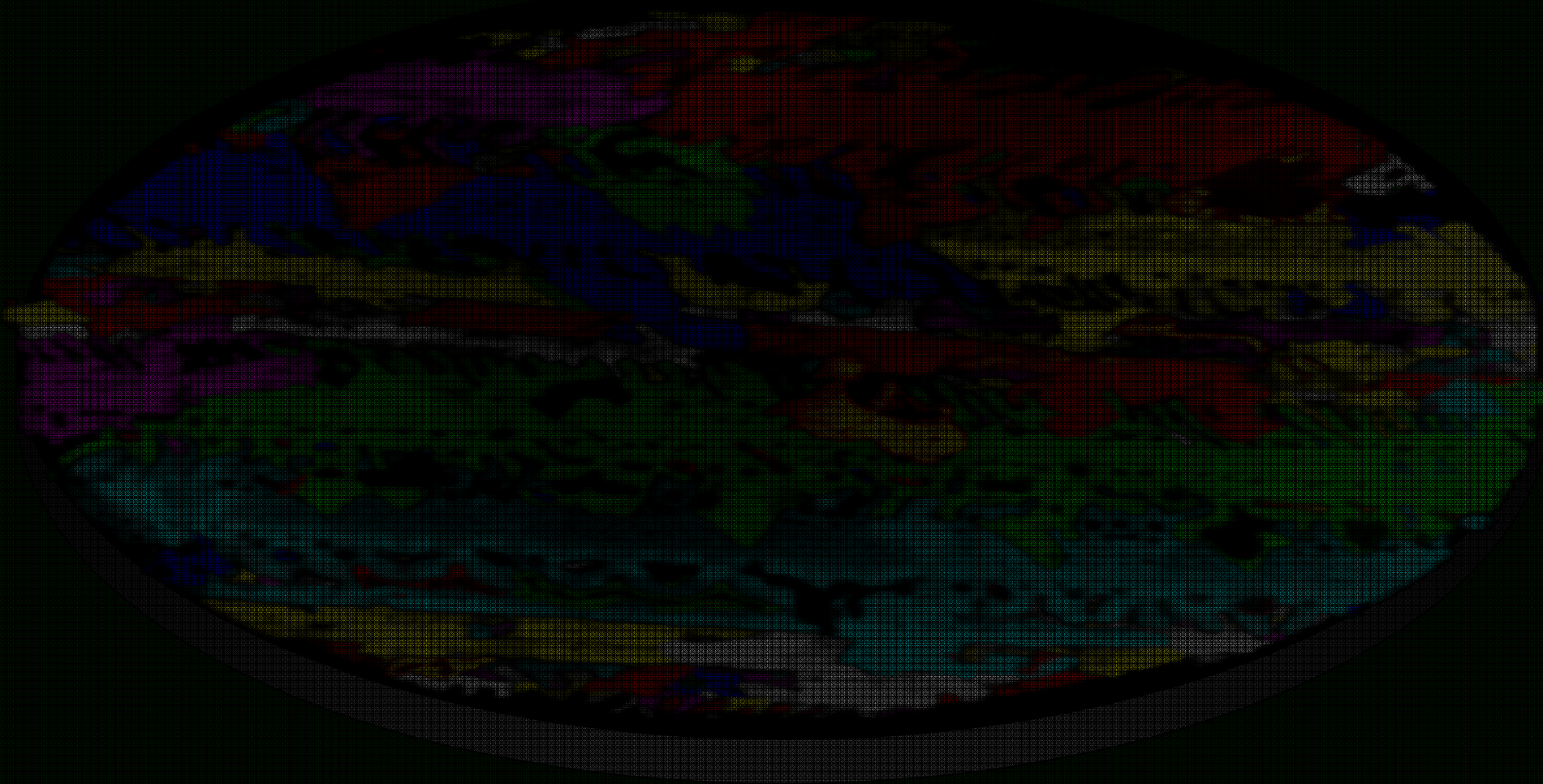


# Summary... So far



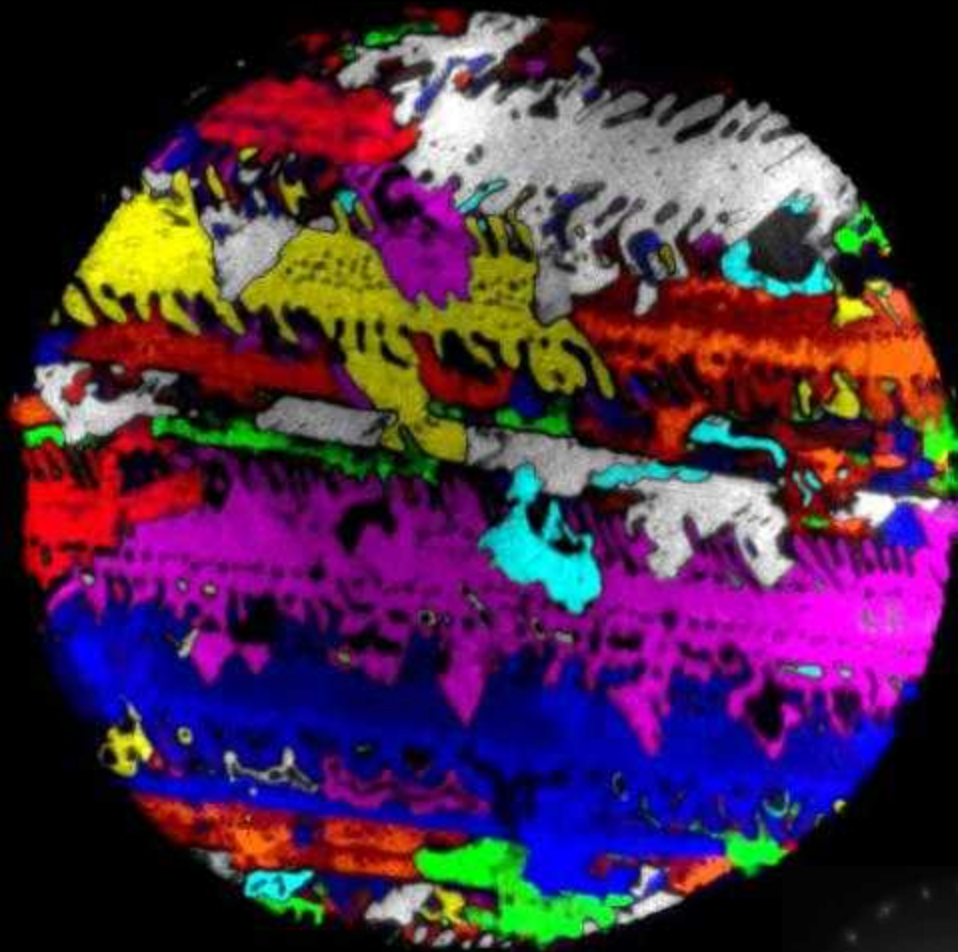
- Different surface reconstructions for fully oxidized and partially reduced YSZ(001)
- On partially reduced YSZ(001), FeO(111) grows with 2 rotational and 2 stacking domains
- Domain rotation and stacking affect the oxide growth rate. Temperature affects domain size
- 2<sup>nd</sup> oxide layer on partially reduced YSZ(001) grows as Fe<sub>3</sub>O<sub>4</sub>(111)
- On fully oxidized YSZ(001), FeO(111) and Fe<sub>2</sub>O<sub>3</sub>(0001) grow simultaneously
- Surfaces easily distinguishable in LEED and LEEM I-V





Ivan Ermanoski, [iermano@sandia.gov](mailto:iermano@sandia.gov) | AVS International Symposium, Nashville, TN, 03. Nov. 2011





FOV=20 $\mu$ m

